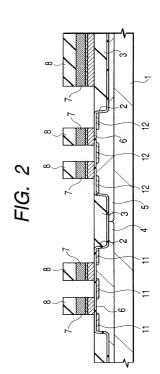
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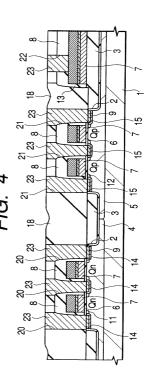
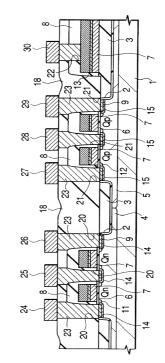
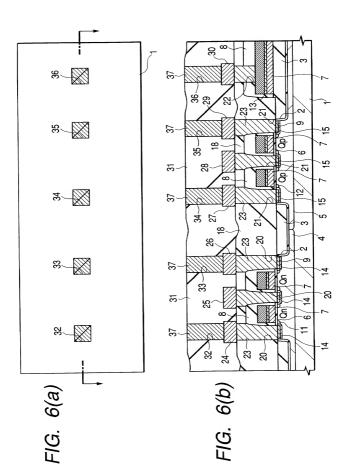
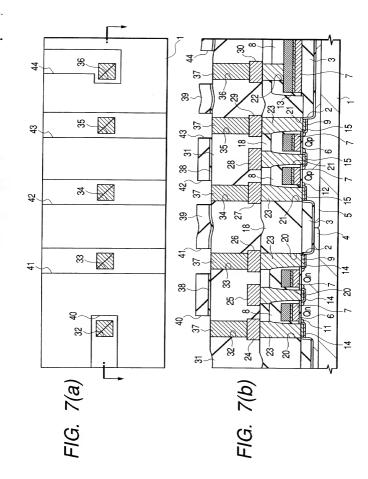


FIG. 5







COMPLETE DECIDE

37 33 **₹** 38 7 FIG. 8 37 4 45 8 នុ 4 8 ล 4 슝. .0 37 Ŕ

FIG. 9

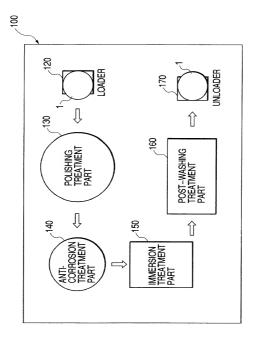


FIG. 10

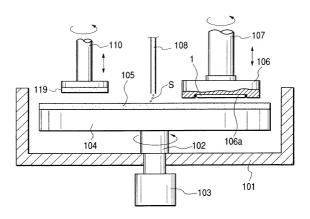


FIG. 11

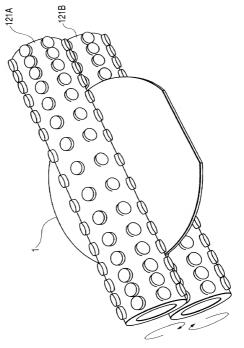


FIG. 12

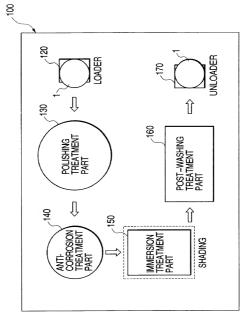


FIG. 13

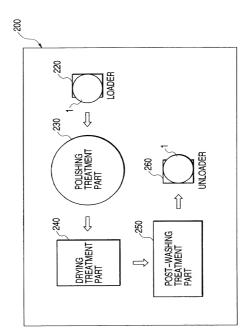
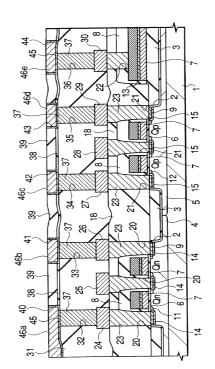


FIG. 14



305 302a 30 333 FIG. 15(b) 302b 316 307 FIG. 15(a) 315 309 31 302a(302b)

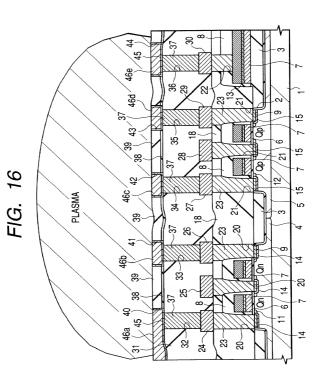


FIG. 17

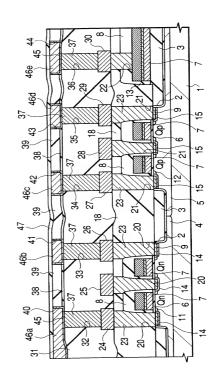


FIG. 18

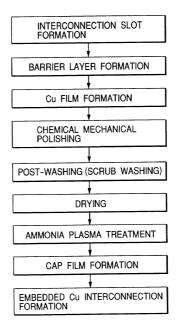


FIG. 19

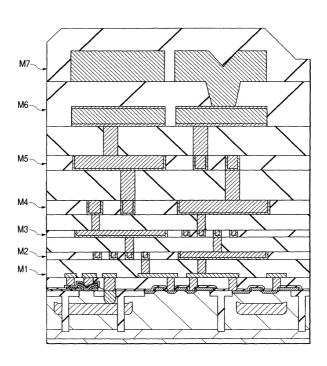


FIG. 20

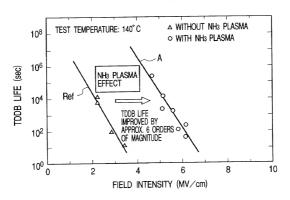
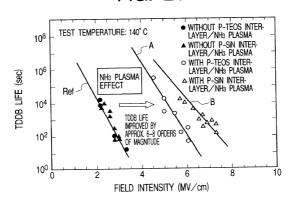
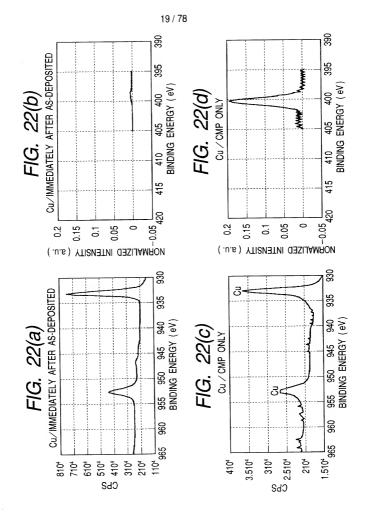
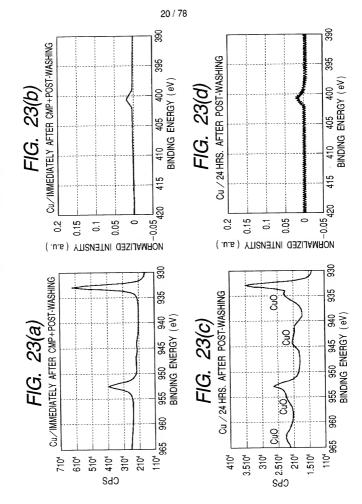
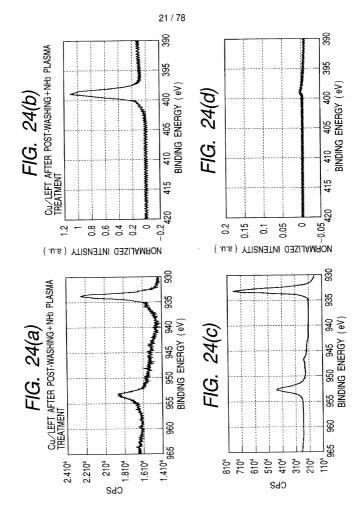


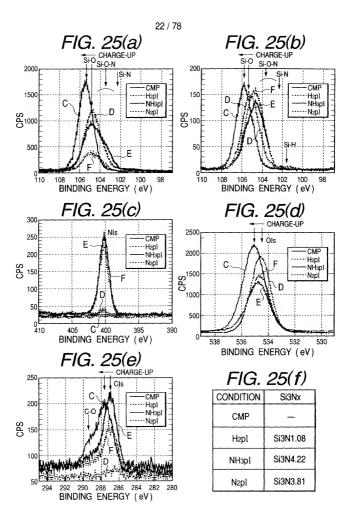
FIG. 21

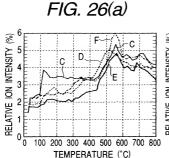






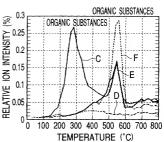




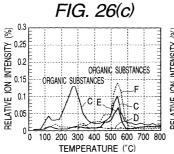


THERMAL DISSOCIATION OF HYDROGEN, Ar-H m/z=41

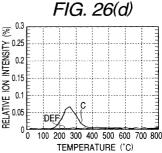
FIG. 26(b)



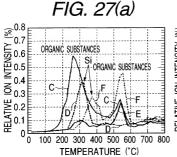
THERMAL DISSOCIATION OF ORGANIC SUBSTANCES, A(CnH2n-1) C2H3 m/z=27



THERMAL DISSOCIATION OF ORGANIC SUBSTANCES, B(CnH2n+1) C4H9 m/z=57

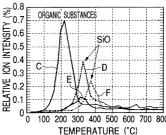


THERMAL DISSOCIATION OF ORGANIC SUBSTANCES, C(CnH2n+10) C3H7O m/z=59



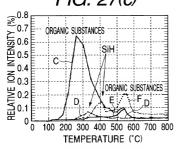
THERMAL DISSOCIATION OF SI AND ORGANIC SUBSTANCES Si, C2H4 m/z=28

FIG. 27(b)



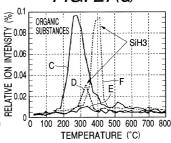
THERMAL DISSOCIATION OF SIO AND ORGANIC SUBSTANCES SIO, C3H6 m/z=44





THERMAL DISSOCIATION OF SIH AND ORGANIC SUBSTANCES SIH, C2H5 m/z=29

FIG. 27(d)



THERMAL DISSOCIATION OF SiH3 AND ORGANIC SUBSTANCES SiH3 m/z=31

FIG. 28

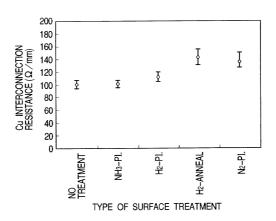


FIG. 29

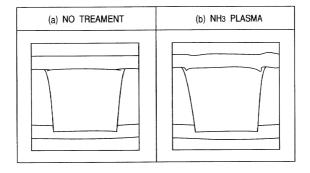
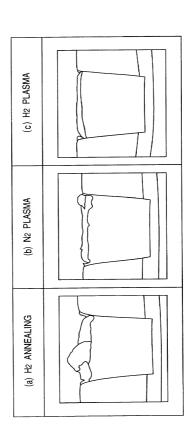
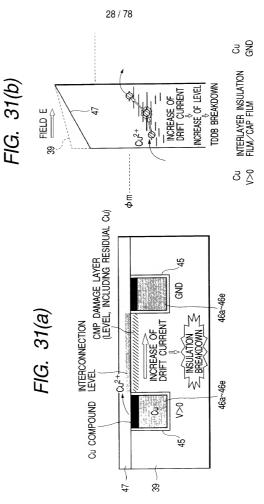


FIG. 30





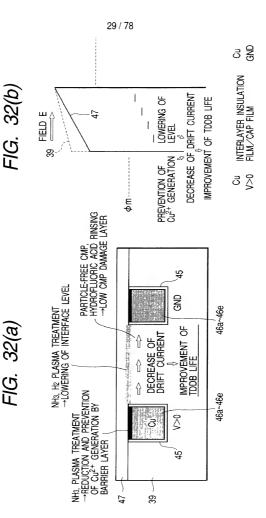
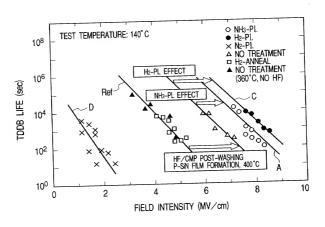


FIG. 33



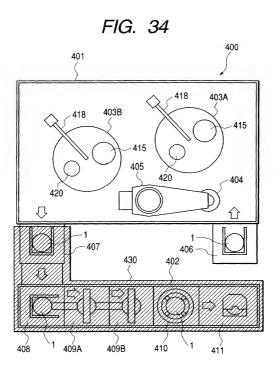


FIG. 35

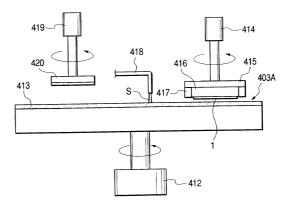


FIG. 36

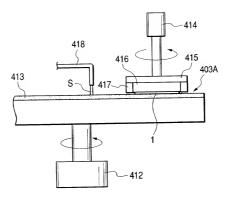


FIG. 37

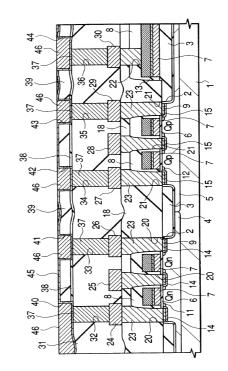


FIG. 38(a)

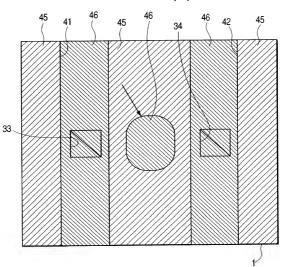


FIG. 38(b)

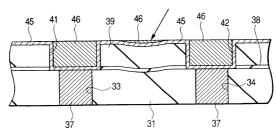


FIG. 39

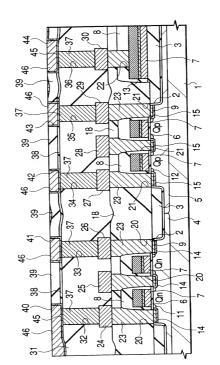


FIG. 40(a)

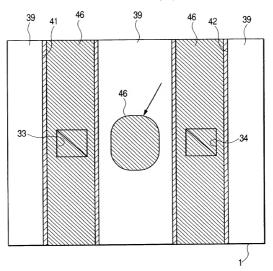


FIG. 40(b)

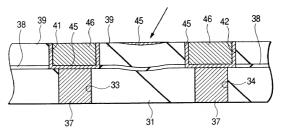
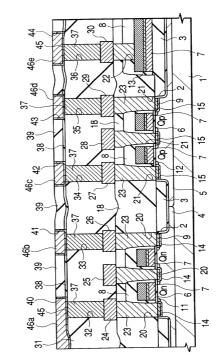


FIG. 41



38 / 78

FIG. 42(a)

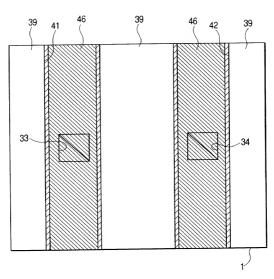


FIG. 42(b)

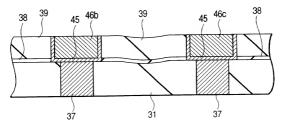


FIG. 43

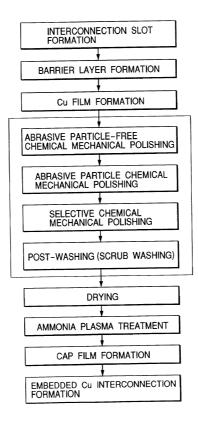


FIG. 44

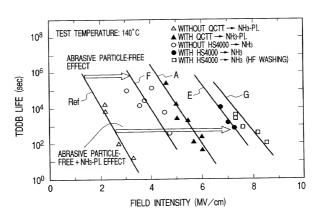


FIG. 45

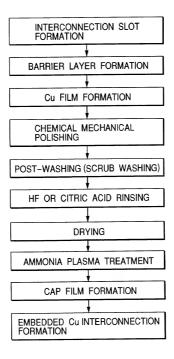


FIG. 46

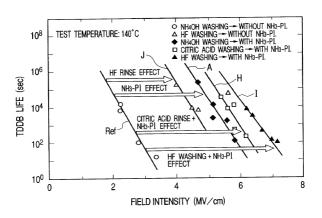


FIG. 47

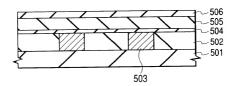


FIG. 48(a)

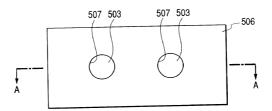


FIG. 48(b)

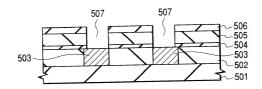
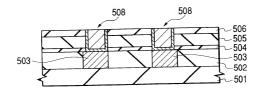
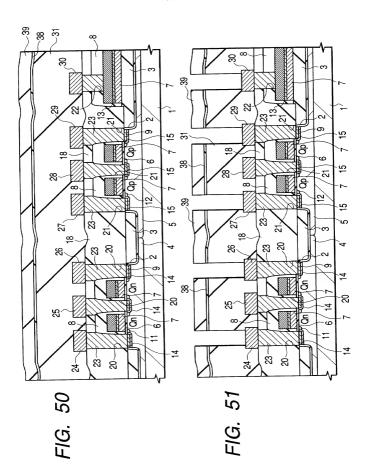
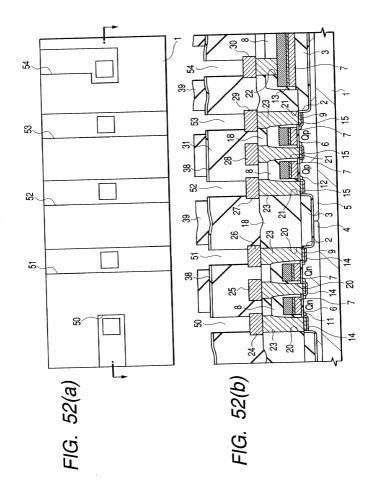


FIG. 49







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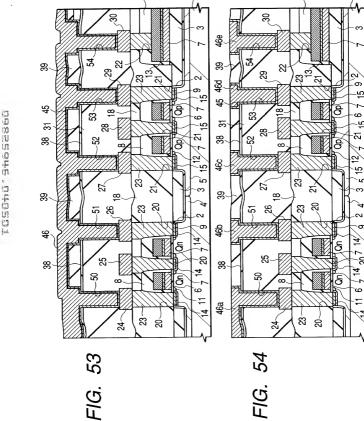


FIG. 55

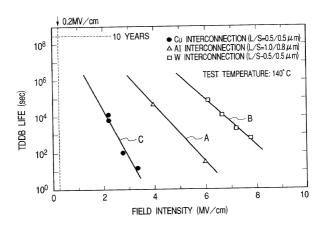
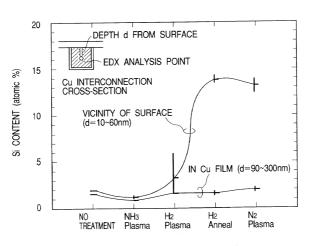
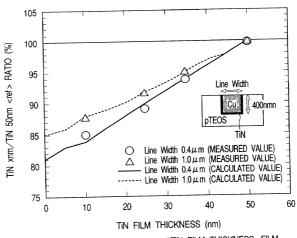


FIG. 56



TYPE OF SURFACE TREATMENT

FIG. 57



*TIN FILM THICKNESS=FILM THICKNESS AT BASE OF SLOT

FIG. 58

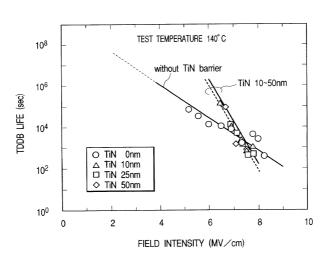


FIG. 59

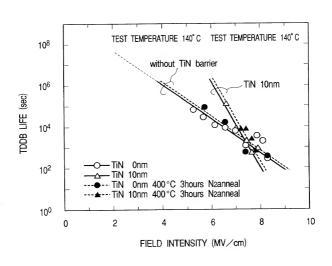


FIG. 60(a)

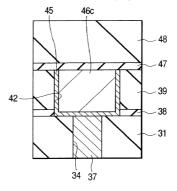


FIG. 60(b)

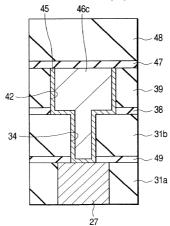


FIG. 61(a)

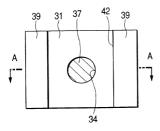


FIG. 61(b)

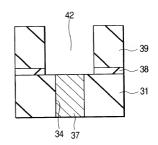


FIG. 62(a)

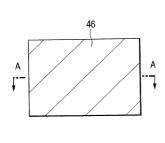
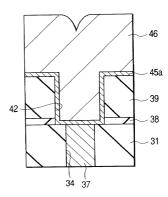
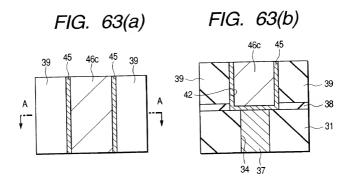


FIG. 62(b)





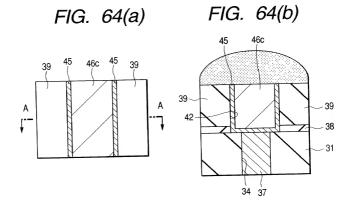


FIG. 65(a)

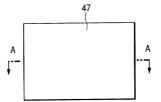


FIG. 65(b)

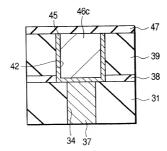


FIG. 66(a)

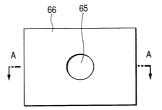


FIG. 66(b)

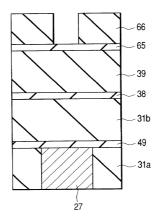


FIG. 67(a)

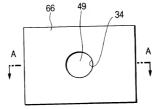


FIG. 67(b)

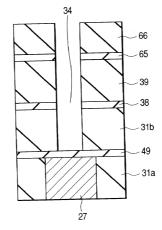


FIG. 68(a)

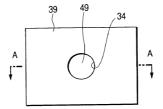


FIG. 68(b)

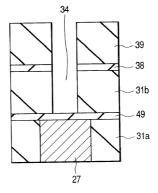


FIG. 69(a)

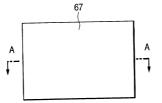


FIG. 69(b)

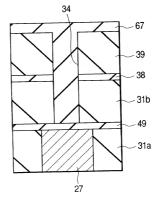


FIG. 70(a)

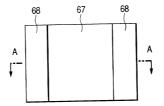


FIG. 70(b)

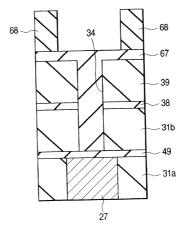


FIG. 71(a)

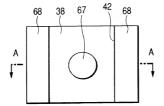


FIG. 71(b)

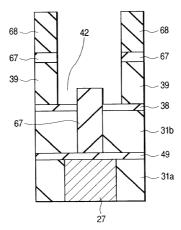


FIG. 72(a)

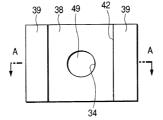


FIG. 72(b)

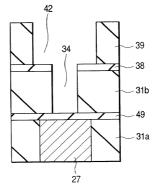


FIG. 73(a)

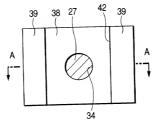


FIG. 73(b)

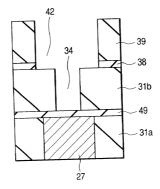


FIG. 74(a)

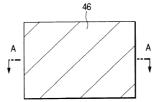


FIG. 74(b)

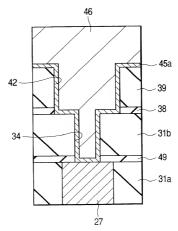


FIG. 75(a)

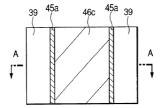


FIG. 75(b)

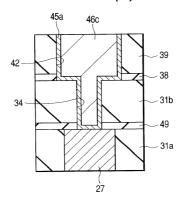


FIG. 76(a)

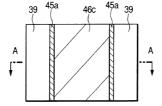
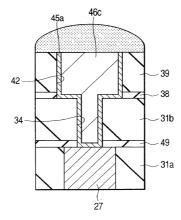
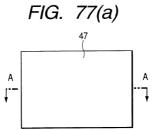


FIG. 76(b)





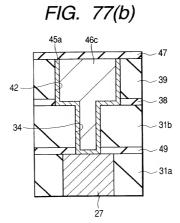


FIG. 78(a)

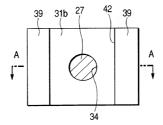
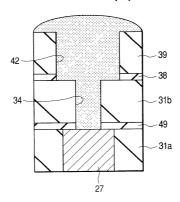
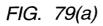


FIG. 78(b)





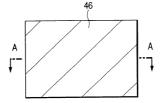
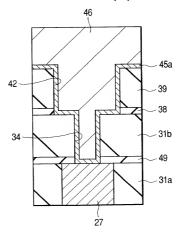


FIG. 79(b)



71 / 78

FIG. 80(a)

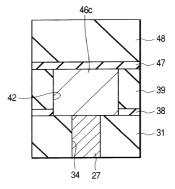


FIG. 80(b)

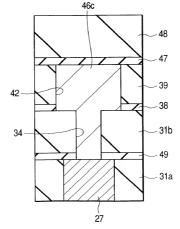


FIG. 81(a)

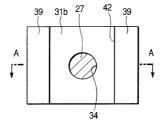


FIG. 81(b)

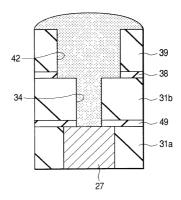


FIG. 82(a)

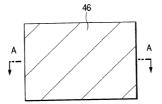


FIG. 82(b)

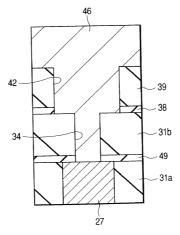


FIG. 83(a)

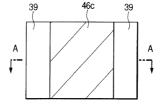
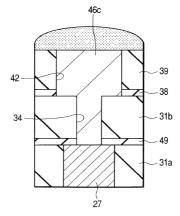


FIG. 83(b)



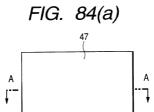


FIG. 84(b)

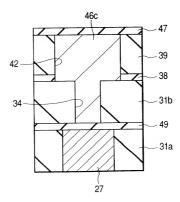


FIG. 85(a)

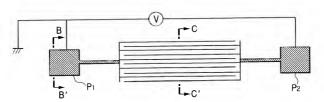


FIG. 85(b)

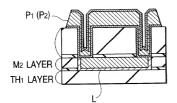


FIG. 85(c)

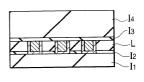


FIG. 86

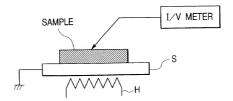


FIG. 87

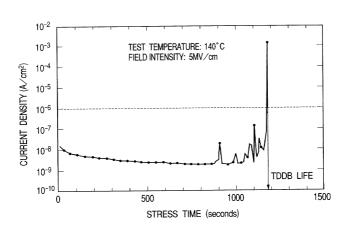


FIG. 88

